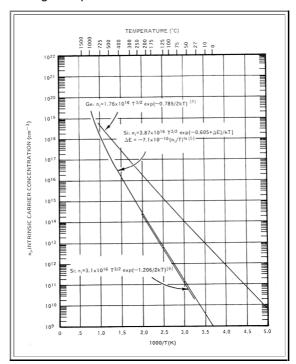
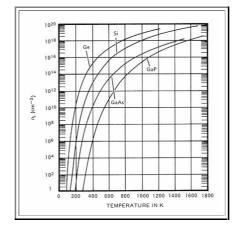
## **Doping and Mobility**

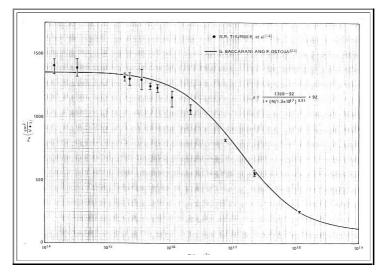
- Shown are some standard diagrams (without detailed comment at present)
  - The first graph gives an **Arrhenius representation** or Arrhenius plot of the *intrinisc carrier concentration* in **Si** and **Ge** for various approximations. The (small) effect of the **T**<sup>3/2</sup> factor can be seen for **Ge**; it is reponsible for the bending of the rather straight line at high temperatures.



The next plot shows the *intrinsic carrier concentration of several semiconductors* as a direct function of the temperature. Note that at room temperature there is a difference of about **7** orders of magnitude.



This plot shows the dependance of the mobility on doping



Semiconductors - Script - Page 1

10<sup>3</sup>

N = 10<sup>19</sup>

Temperature (°C)

This is the combined result of carrier concentration and mobility: The *resisitivity of Si* as a function of doping for electrons and holes separately.

